



US00D851613S

(12) **United States Design Patent**
Johanson et al.

(10) **Patent No.:** **US D851,613 S**
(45) **Date of Patent:** **** Jun. 18, 2019**

(54) **TARGET PROFILE FOR A PHYSICAL VAPOR DEPOSITION CHAMBER TARGET**

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(71) Applicant: **APPLIED MATERIALS, INC.**, Santa Clara, CA (US)

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(72) Inventors: **William Johanson**, Gilroy, CA (US); **Kirankumar Savandaiah**, Bangalore (IN); **Anthony Chih-Tang Chan**, Sunnyvale, CA (US); **Siew Kit Hoi**, Singapore (SG); **Prashant Prabhakar Prabhu**, Karwar (IN)

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(73) Assignee: **APPLIED MATERIALS, INC.**, Santa Clara, CA (US)

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(**) Term: **15 Years**

Primary Examiner — Elizabeth J Oswecki

(21) Appl. No.: **29/621,221**

(74) *Attorney, Agent, or Firm* — Moser Taboada; Alan Taboada

(22) Filed: **Oct. 5, 2017**

(57) **CLAIM**

(51) **LOC (11) Cl.** **13-03**

The ornamental design for a target profile for a physical vapor deposition chamber target, as shown and described.

(52) **U.S. Cl.**
USPC **D13/182**

DESCRIPTION

(58) **Field of Classification Search**
USPC D13/182; D15/144.1, 144.2, 199
CPC H01L 21/67742; H01L 21/0226; H01L 21/02263; H01L 21/02266; H01L 21/02269; H01L 21/02271; H01L 2224/75186; H01L 2224/761185; H01L 2224/76186; H01L 2221/68363
See application file for complete search history.

FIG. 1 is a top perspective view of a target profile for a physical vapor deposition chamber target, showing our new design;
FIG. 2 is a bottom perspective view thereof;
FIG. 3 is a top plan view thereof;
FIG. 4 is a bottom plan view thereof;
FIG. 5 is a right side elevational view thereof;
FIG. 6 is a left side elevational view thereof;
FIG. 7 is a front elevational view thereof;
FIG. 8 is a back elevational view thereof; and,
FIG. 9 is an enlarged cross sectional view taken along line 9-9 in FIG. 4.

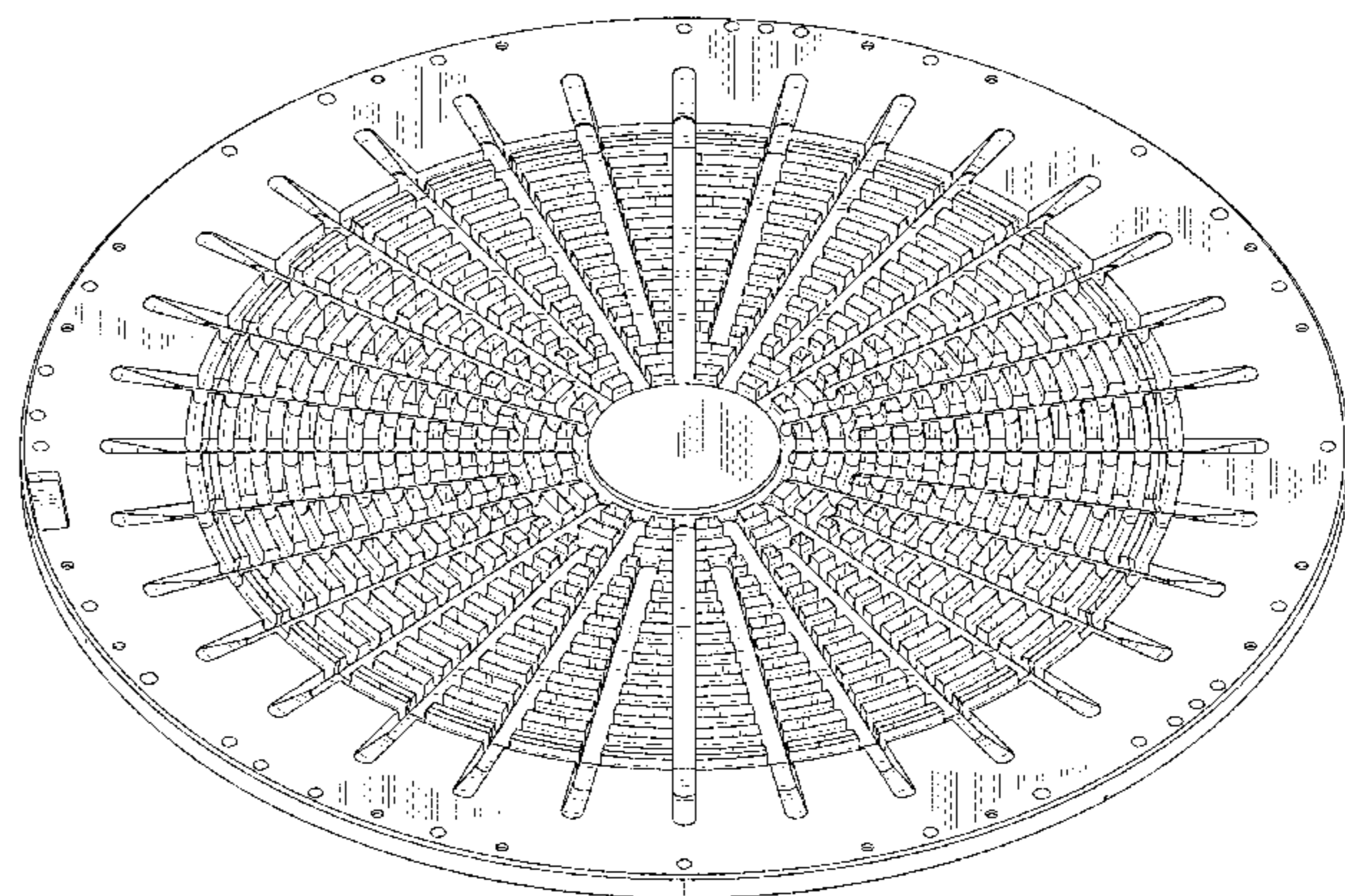
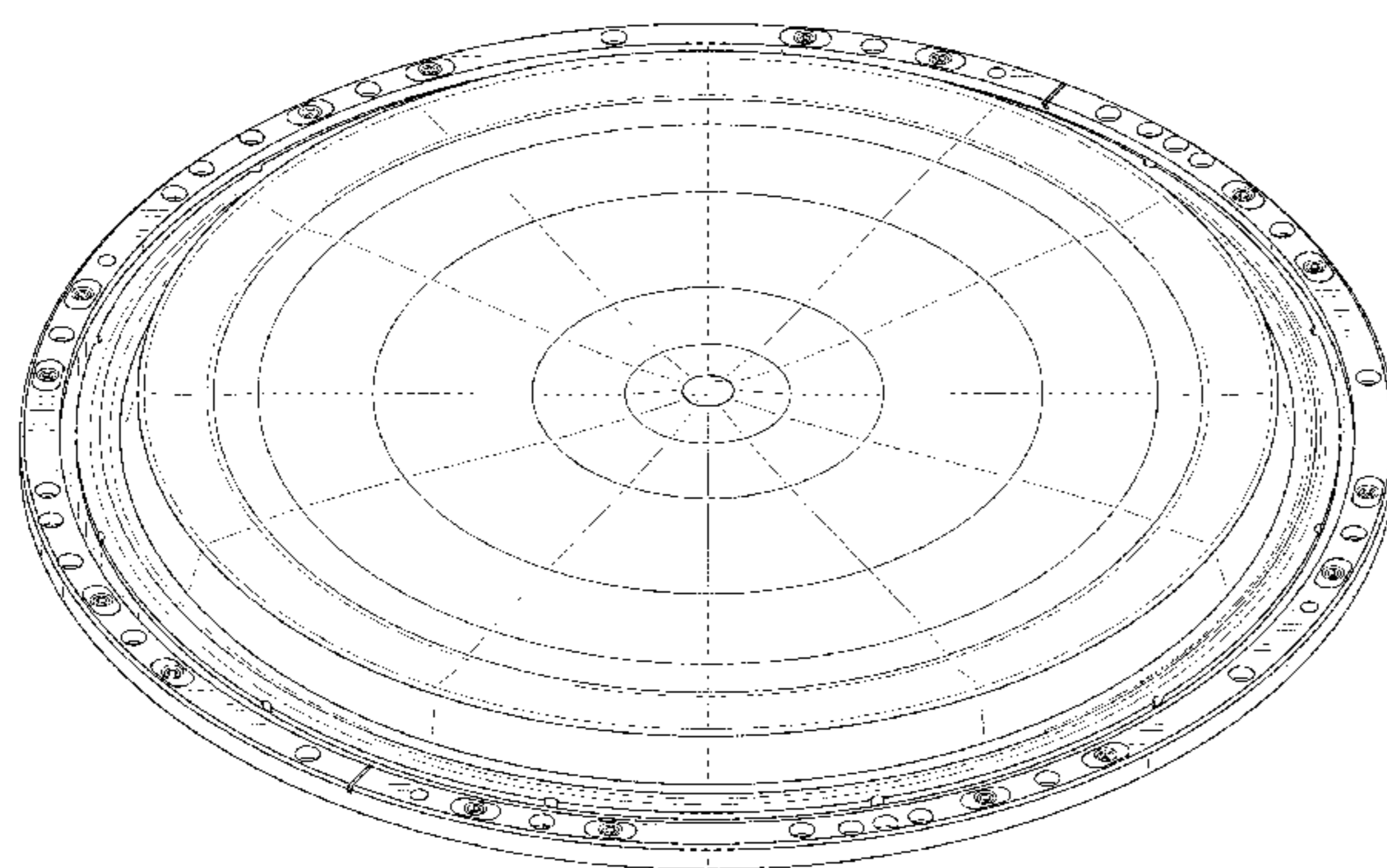
The dashed lines of the cut line showing the plane upon which FIG. 9 is taken in FIG. 4 forms no part of the claimed design.

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1 Claim, 7 Drawing Sheets



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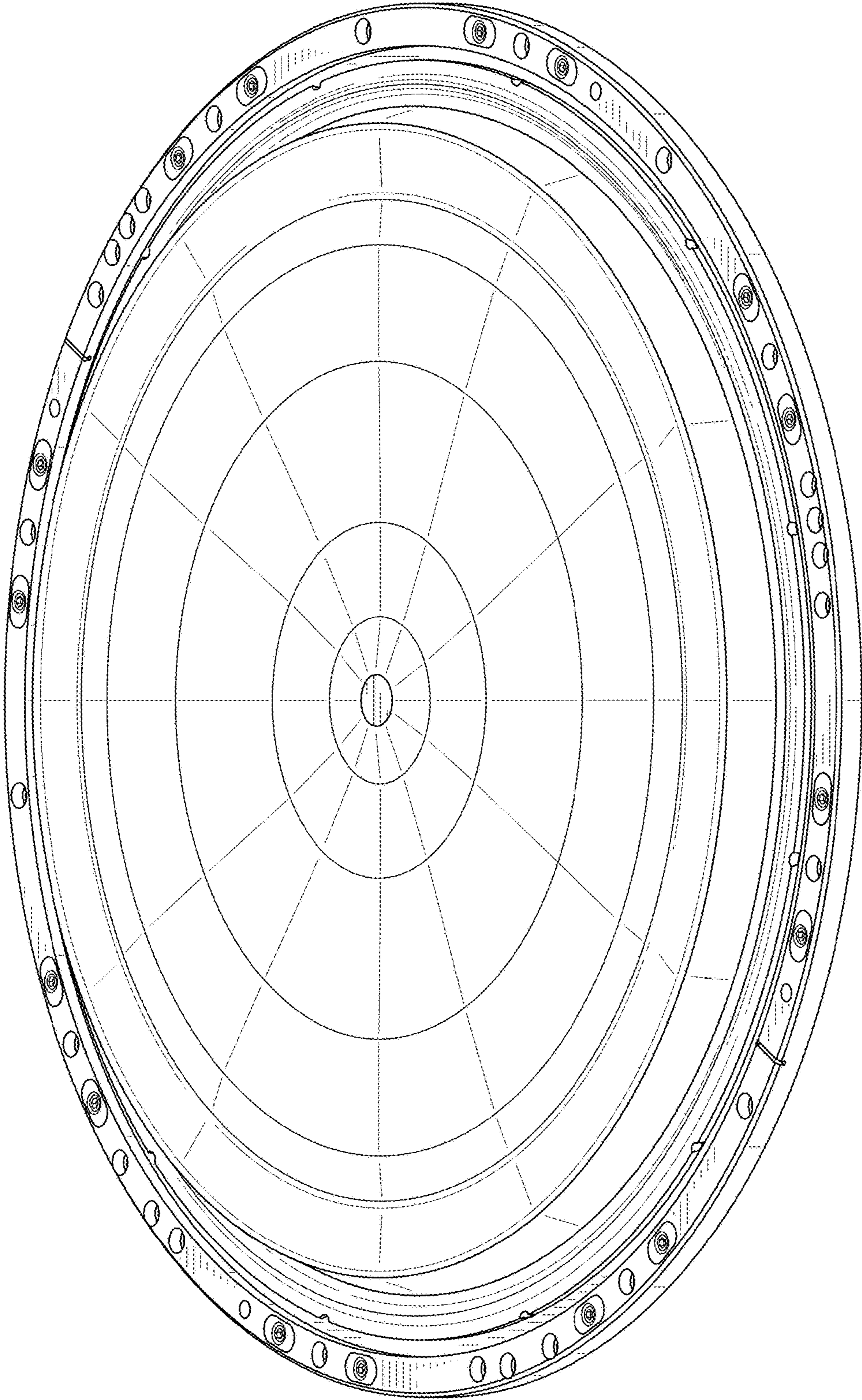


FIG. 1

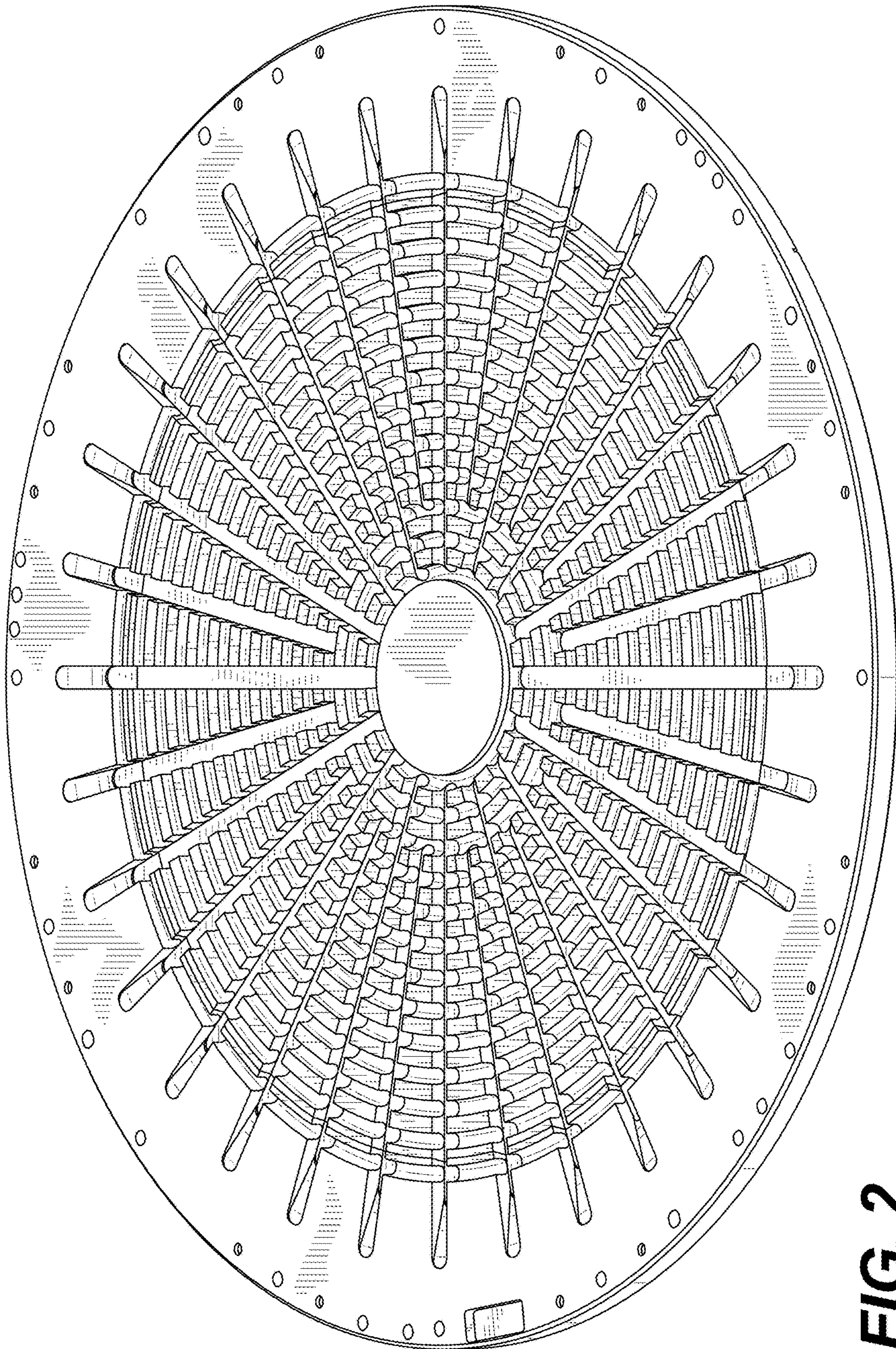


FIG. 2

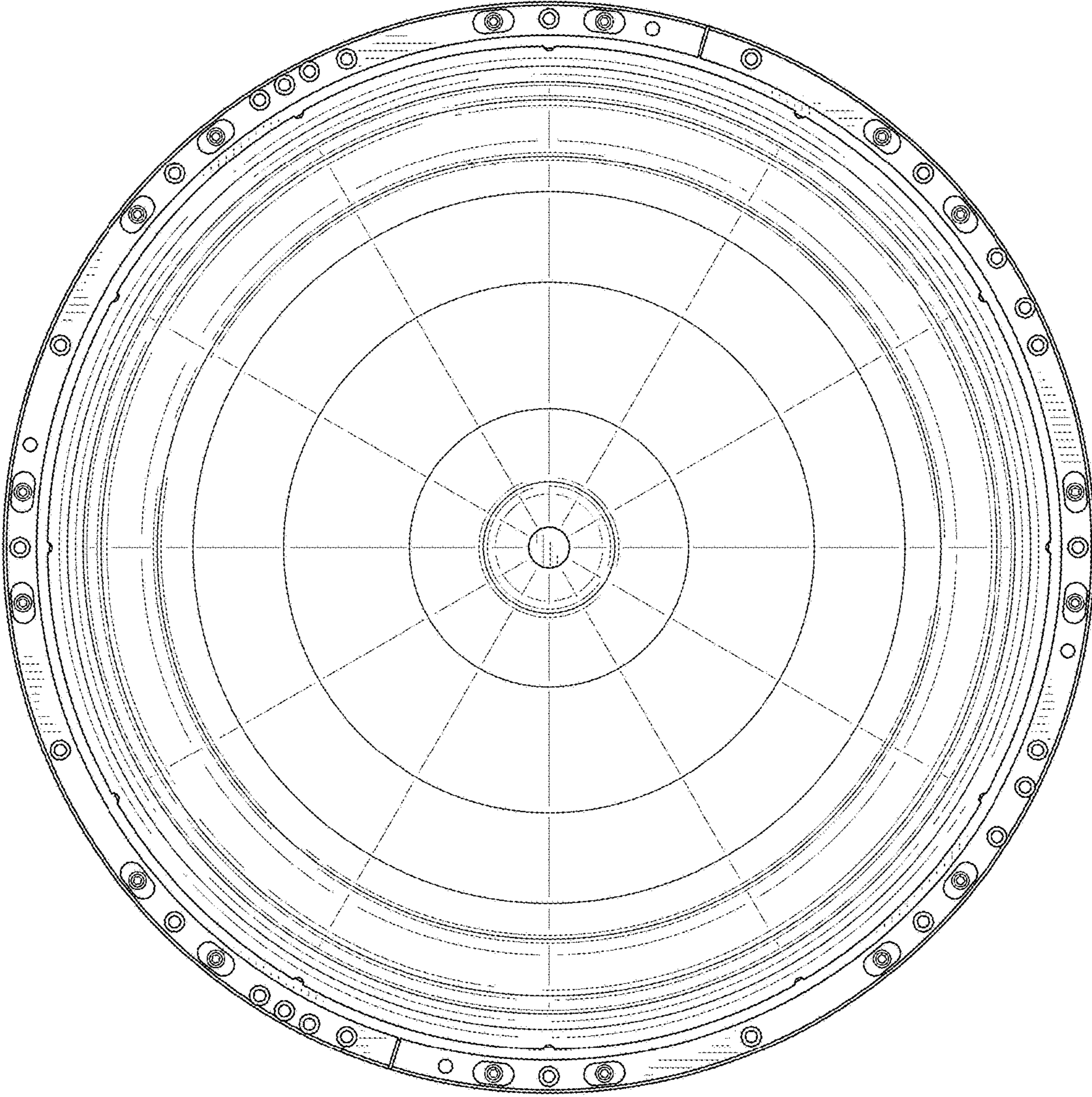


FIG. 3

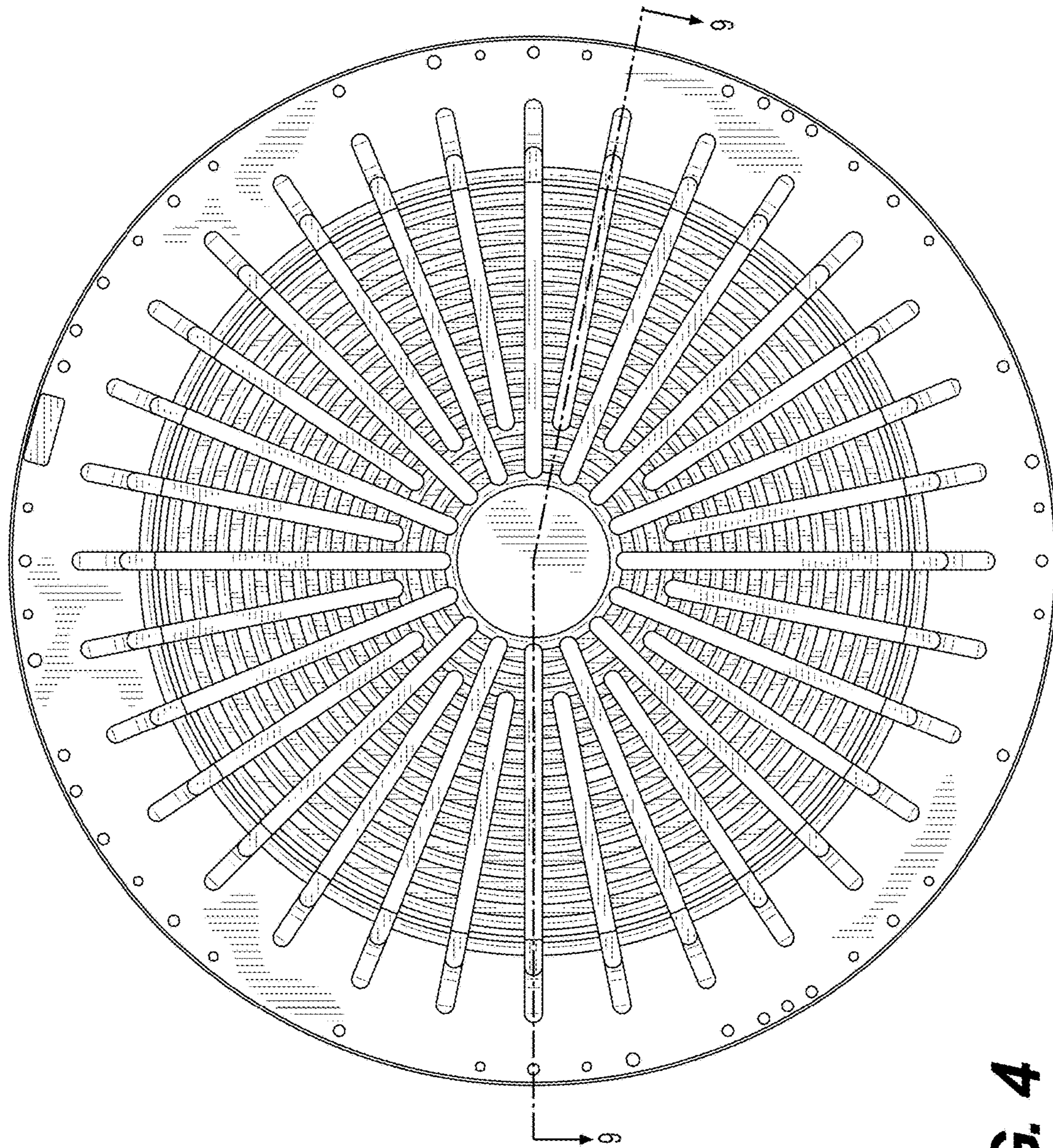


FIG. 4

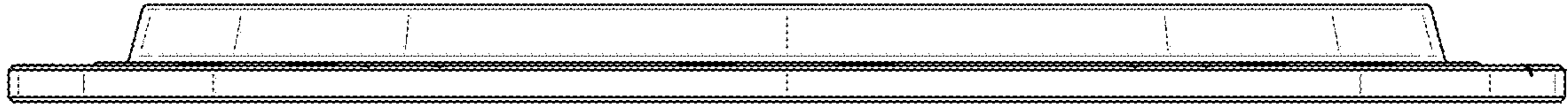


FIG. 5

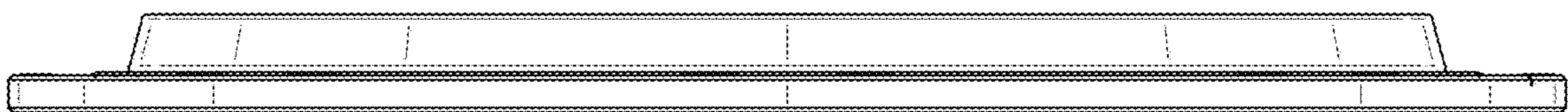


FIG. 6

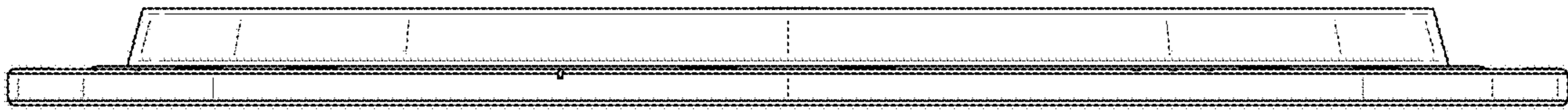


FIG. 7

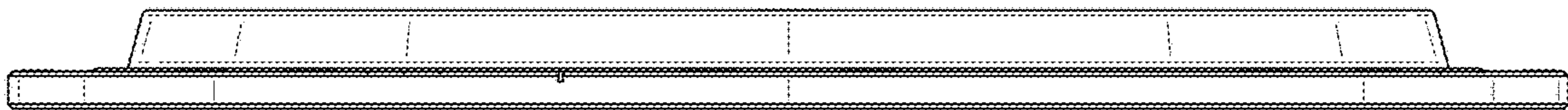


FIG. 8

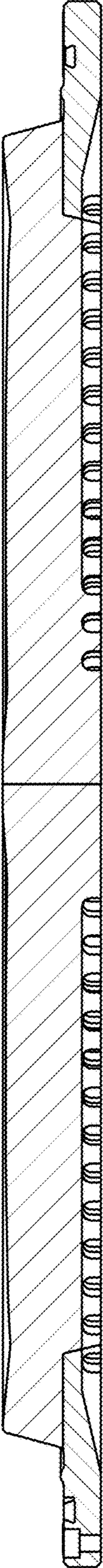


FIG. 9